Rates for Lab or Tool Self-Use

	Rate ($/hr)	
	UC System	**For-profit and Non-US**
Cleanroom		
Cleanroom Use	24	85
Heidelberg Maskless Aligner*	38	94
Denton 635 Sputter Coater*	16	40
Denton 18 Sputter Coater*	16	40
Atomic Layer Deposition*	21	53
Ebeam Evaporator 1*	16	41
Ebeam Evaporator 2*	16	41
Oxford P80 Dry Etcher*	21	53
Trion Plasma Etcher*	21	53
Plasma-Therm Dry Etcher*	21	53
Oxford P100 Dry Etcher*	21	53
Parylene Coater*	11	28
AJA DC Sputter*	21	53
AJA RF Sputter*	21	53
Oxford PECVD*	21	53
Plasma-Therm PECVD*	27	67
Oxford Cobra Dry Etcher*	37	90
NanoFrazor*	27	67
Flip Chip Bonder*	37	90
* Rate reflects equipment surcharge only; it does not include the Cleanroom Use rate, which will be applied while the user is in the Cleanroom.		
Analytical Labs		
Dicing	58	138
Talos F200X G2 S/TEM	76	174
Analytical Lab Use	24	103
FEI Scios DualBeam FIB/SEM**	53	93
FEI Quanta FEG250 SEM**	38	61
FEI Apreo SEM**	48	74
Zeiss Sigma 500 SEM**	49	76
Park AFM**	27	66
PHI XPS**	51	158
** Rate reflects equipment surcharge only; it does not include the Analytical Lab Use rate, which will be applied while the user is in the lab.		

Other Rates		
	UC System	**For-profit and Non-US**
New User Fee -Per user	$150	$250
General Staff Service	$90/hour	$159/hour
EBL Machine Time	$175/hour	$348/hour

Please note that the rates listed above are not exhaustive.